

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Alex A. Behfar, et al.) Docket No. BIN 9/US
Application No. : 10/802,734)
Filed: March 18, 2004) Examiner: Golub, Marcia A.
For: High SMSR Unidirectional Etched)
Lasers and Low Back-Reflection)
Photonic Device)

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Responsive to the Office Action dated December 7, 2009, please amend the claims as set forth in the following section.

Applicants request that the time period for responding be extended two months to May 7, 2010. The \$245.00 extension fee is being paid upon EFS filing of this Amendment.